

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S16 1	111	(((((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compressive or compressively or tensile)) ) and ((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting))) and (cmos or complementary or complimentary)) and (stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting)))	US-PGPUB; USPAT	OR	ON	2005/11/20 12:44
S20 6	16	S205 and stress	US-PGPUB; USPAT	OR	ON	2005/11/20 12:45
S20 4	0	(((((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compressive or compressively or tensile)) ) and ((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting))) and (cmos or complementary or complimentary)) and (stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting))) and S201	US-PGPUB; USPAT	OR	ON	2005/11/20 12:45
S20 5	38	(silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) and S201	US-PGPUB; USPAT	OR	ON	2005/11/20 12:46
S20 8	1	amberwave.as. and @pd="20030227"	DERWENT	OR	ON	2005/11/20 13:22
S20 7	4	((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with stress) and S201	US-PGPUB; USPAT	OR	ON	2005/11/20 13:22
S41	4	(((((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compressive or compressively or tensile)) ) and ((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting))) and (cmos or complementary or complimentary)) and (stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting)))	US-PGPUB; USPAT	OR	ON	2005/11/20 15:07
S20 9	141	(((((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compressive or compressively or tensile)) ) and ((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting))) and (cmos or complementary or complimentary)) and (stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting)))	US-PGPUB; USPAT	OR	ON	2005/11/20 15:08
S21 5	53	S214 and (("257"/\$3.cor.) or ("438"/\$3.cor.))	US-PGPUB; USPAT	OR	ON	2005/11/20 15:11
S21 4	59	S213 and (@ad<"20040226" or @rlad<"20040226")	US-PGPUB; USPAT	OR	ON	2005/11/20 15:11
S21 2	65	S211 and (("257"/\$3.cor.) or ("438"/\$3.cor.))	US-PGPUB; USPAT	OR	ON	2005/11/20 15:11
S21 1	130	S210 and (@ad<"20040226" or @rlad<"20040226")	US-PGPUB; USPAT	OR	ON	2005/11/20 15:11

S21 0	141	((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compressive or compressively or tensile) ) and ((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting)) and (cmos or complementary or complimentary) and (stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting)) and (cmos or complementary or complimentary))	US-PGPUB; USPAT	OR	ON	2005/11/20 15:11
S21 3	62	((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compressive or compressively or tensile) ) and ((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting)) and (cmos or complementary or complimentary))	US-PGPUB; USPAT	OR	ON	2005/11/20 15:11
S21 6	16	S215 and (stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1implanting))	US-PGPUB; USPAT	OR	ON	2005/11/20 15:25
S21 7	1	"20050093078"	US-PGPUB; USPAT	OR	ON	2005/11/20 15:25
S37	1077	((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compressive or compressively or tensile))	US-PGPUB; USPAT	OR	ON	2005/11/22 21:24
S21 8	1	(silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) and "20050093078".did.	US-PGPUB; USPAT	OR	ON	2005/11/22 21:26